

Фамилия, имя, отчество	Якимов Евгений Борисович
Должность, ученая степень, ученое звание	Профессор, д.ф.-м.н.
Электронная почта	yakimov.eb@misis.ru
Рабочий телефон	+7 499 237-21-29
Область научных интересов	Материаловедение полупроводников
Трудовая деятельность	1971-1984 ИФТТ РАН, 1984-н.в. – ИПТМ РАН
Значимые публикации	<p>1. A.Y. Polyakov, N.B. Smirnov, I.V.Schemerov, A.V. Chernykh, E.B. Yakimov, A.I. Kochkova, A.N. Tereshchenko, S.J. Pearton. Electrical Properties, Deep Levels and Luminescence Related to Fe in Bulk SemiInsulating β-Ga₂O₃ Doped with Fe. ECS J. Solid State Sci. Technol., 8, Q3091-Q3096 (2019).</p> <p>2. A.Y. Polyakov, N.B. Smirnov, I.V. Shchemerov, E.B. Yakimov, V.I. Nikolaev, S.I. Stepanov, A.I. Pechnikov, A.V. Chernykh, K.D. Shcherbachiev, A.S. Shikoh, A. Kochkova, A.A. Vasilev, S.J. Pearton. Deep trap spectra of Sn-doped Ga₂O₃ grown by halide vapor phase epitaxy on sapphire. APL Mater. 7, 051103 (2019).</p> <p>3. A.Y. Polyakov, In-Hwan Lee , N.B. Smirnov, E.B. Yakimov , I.V. Shchemerov, A.V.Chernykh, A.I. Kochkova, A.A. Vasilev, P.H. Carey , F. Ren , D.J. Smith, S.J. Pearton. Defectsat the surface of \square-Ga₂O₃ produced by Ar plasma exposure. APL Mater. 7, 061102 (2019).</p> <p>4. A. Y. Polyakov, In-Hwan Lee, N. B. Smirnov, E. B. Yakimov, I. V. Shchemerov, A. V. Chernykh, A. I. Kochkova, A. A. Vasilev, F.Ren, P. H. Carey, and S. J. Pearton Hydrogen plasma treatment of \square-Ga₂O₃: Changes in electrical properties and deep trap spectra. Appl. Phys. Lett. 115, 032101 (2019).</p> <p>5. A.Y. Polyakov, In-Hwan Lee, N.B. Smirnov, E.B. Yakimov, I.V. Shchemerov, A.V. Chernykh, A.I. Kochkova, A.A. Vasilev, A.S. Shiko, P.H. Carey IV, F. Ren, S.J. Pearton. Effects of Hydrogen Plasma Treatment Condition on Electrical Properties of β-Ga₂O₃ ECS J. Solid State Sci. Technol., 8, P661-P666 (2019).</p> <p>6. A.Y. Polyakov, V.I. Nikolaev, S.I. Stepanov, A.I. Pechnikov, E.B. Yakimov, N.B. Smirnov, I.V. Shchemerov, A.A. Vasilev, A.I. Kochkova, A.V. Chernykh, S.J. Pearton. Electrical Properties and Deep Traps in α-Ga₂O₃:Sn Films Grown on Sapphire by Halide Vapor Phase Epitaxy. ECS J. Solid State Sci. Technol., 2020, 9, 045003</p> <p>7. O.V. Feklisova, E.E. Yakimov, E.B.Yakimov. Study of single-layer stacking faults in 4H–SiC by deep level transient spectroscopy. Appl. Phys. Lett. 116, 172101, 2020.</p> <p>8. A.Y. Polyakov, N.B. Smirnov, I.V. Shchemerov, A.A. Vasilev, E.B. Yakimov, A.V. Chernykh, A.I. Kochkova, P.B. Lagov, Yu.S. Pavlov, O.F. Kukharchuk, A.A. Suvorov, N.S. Garanin, In-Hwan Lee, M. Xian, F. Ren, and S.J. Pearton. Pulsed fast reactor neutron irradiation effects in Si doped n-type -Ga₂O₃. J. Phys. D: Appl. Phys. 53 (2020) 274001.</p> <p>9. E.E. Yakimov, E.B. Yakimov. Radiation enhanced dislocation glide in 4H-SiC at low temperatures. J. Alloys Compds 837 (2020) 155470.</p> <p>10. E.B. Yakimov, A.Y. Polyakov, N.B. Smirnov, I.V. Shchemerov, P.S. Vergeles, E.E. Yakimov, A.V. Chernykh, M. Xian, F. Ren, S.J. Pearton. Role of hole trapping by deep acceptors in electron-beam-induced current measurements in β-Ga₂O₃ vertical rectifiers. J. Phys. D: Appl. Phys. 53 (2020) 495108.</p>
Индекс Хирша по Scopus	

Количество статей по

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На усмотрение:

SPIN РИНЦ

ORCID

ResearcherID

Scopus AuthorID

8393-7666

0000-0001-8100-879X

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